

Charge transport through ultrasmall single and double Josephson junctions coupled to resonant modes of the electromagnetic environment

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(Dated: February 15, 2022)

We have investigated charge transport in ultrasmall superconducting single and double Josephson junctions coupled to resonant modes of the electromagnetic environment. We observe pronounced current peaks in the transport characteristics of both types of devices and attribute them to the process involving simultaneous tunneling of Cooper pairs and photon emission into the resonant modes. The experimental data is well reproduced with the theoretical models.

Charge tunneling in ultrasmall junctions is affected by the electromagnetic environment (EE) [1, 2]. For example, the same tunnel junction placed in different EEs exhibits different transport characteristics [3]. It was understood that the tunneling charge probes the electromagnetic environment at certain distances, thus forming a coupled junction+environment system [4]. Similar physics governs the single-electron transistor (SET) [1], but now resulting in characteristics that are periodically modulated by the gate voltage.

For single junctions these ideas were developed into a relatively simple model, nicknamed $P(E)$ -theory [5], in which the function $P(E)$ describes the probability for the tunneling electrons (charges) to exchange energy E with the environment. Due to the progress in nanofabrication, it became possible to engineer on-chip EE by using various techniques. For example, high-impedance environment can be created by placing miniature thin-film resistors in the dc leads in the vicinity of the tunnel junction [6, 7]. It is also possible to construct an environment with distinct, well-characterized resonance modes [8, 9].

Although the effect of the resonant EE is well understood and received sufficient experimental support [8, 9] and theoretical explanations [10] in the case of a single Josephson junction (JJ), clear experimental data for transport properties is still lacking in the case of a superconducting SET (SSET). The SSET coupled to a lossy transmission line was studied experimentally in Ref. [11], and some signatures of the environmental modes were observed. In the present work, we report our transport measurements on single and double Josephson junctions coupled to distinct electromagnetic modes of the environment. Both types of devices reveal characteristic peak structure in transport that is interpreted to arise from the

interaction of the tunneling Cooper pairs with the resonant environment. The experimental data of the SSET is well reproduced by the theory applying density matrix to Cooper pair tunneling in the presence of the (i) environmental modes, identified in the single JJ experiment, and (ii) substantial subgap electronic density of states in the superconducting Nb island. The observed resonances appear to be generic for the structures having metallic leads on the surface of, e.g., Si chips, unless a special care is taken to suppress them.

The configuration of our chips is shown in the inset of Fig. 1. The samples consist of Al/AlO_x/Nb tunnel junctions and Al/AlO_x/Nb/AlO_x/Al single-electron transistors made by electron-beam lithography [13] and embedded into Au leads prefabricated photolithographically on a silicon chip. In addition to the Al/Nb junctions, an all-Al junction was also measured. The Si chip of thickness 0.3 mm with a 300 nm thick oxidized layer on top is placed in a copper sample package forming a ground plane at the bottom of the chip. The Au leads and the ground plane form microstrips on both sides of the junctions/transistors with a wave impedance $Z_0 \approx 40 \Omega$. The microstrips are bonded with 0.025 mm Au wire to the cryostat wires for dc measurements. The impedance of the bonding wire ($Z_L \sim 200 \Omega$) creates an impedance mismatch. Therefore, the microstrips resonate approximately at frequencies $n\omega_0$, where n is an integer and $\omega_0 = \pi c / \sqrt{\varepsilon_e} \ell$ is the fundamental frequency corresponding to the $\lambda/2$ resonance. Here c is the speed of light in vacuum, $\varepsilon_e \approx 7$ is the effective dielectric constant of the microstrip [12] and $\ell \approx 1.9$ mm is the microstrip length. These numbers give the resonance frequency $\omega_0/2\pi \approx 30$ GHz. With the resistance of each Au lead measured at subKelvin temperature $R_{\text{Au}} \approx 3.5 \Omega$ we estimate the microstrip resonator quality factor $Q \approx 5$, which is mostly determined by the external impedance of 200 Ω . Measurements were done using a two-probe scheme in a dilution refrigerator at a base temperature of about 40 mK.

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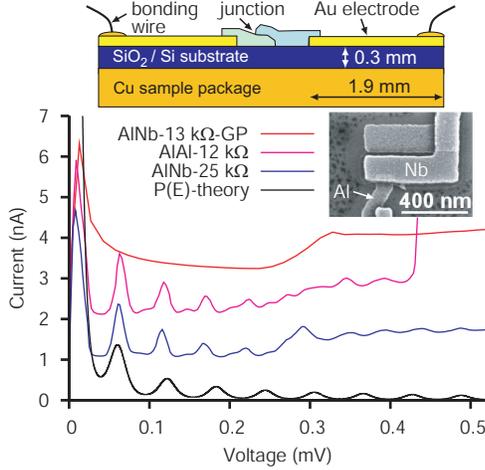


FIG. 1: (Color online) Current as a function of bias voltage through single Josephson junctions embedded in a resonant environment and the $P(E)$ -theory result with the quasiparticle tunneling neglected. For one junction, AlNb-13 k Ω -GP, the environmental resonances were suppressed by using a ground plane right beneath the Au leads. The experimental curves are shifted by 1, 2 and 3 nA, respectively, from bottom to top. The normal state resistances in the legend were used to deduce the Josephson coupling energies using the Ambegaokar-Baratoff relation [14], $\Delta_{\text{Al}} = 215 \mu\text{eV}$, $\Delta_{\text{Nb}} = 1.15 \text{ meV}$ and $T = 100 \text{ mK}$. The Josephson coupling energy of the AlNb-25 k Ω junction is practically the same as of the AlAl-12 k Ω junction ($E_J = 57 \mu\text{eV}$), for which the simulation is made. The EE is characterized in the text. Inset: chip layout (not to scale) and scanning electron micrograph of the AlNb single junction.

A collection of the single junction dc current-voltage (I - V) characteristics at the subgap voltage is shown in Fig. 1. The common feature of the junctions measured, regardless of the electrode materials, is that at low bias voltage they all exhibit approximately equidistant peak structure. The peak position does not depend on the junction resistance. The location of the first peak at a bias voltage of $\approx 61 \mu\text{V}$ agrees with the estimated resonance frequency ω_0 through the relation $2eV = \hbar\omega_0$ (leading to $\omega_0/2\pi = 29.4 \text{ GHz}$).

The peaks are suppressed if an additional ground plane is placed beneath the leads separated by a thin insulating layer, see Fig. 1. In this case the Au leads do not form microstrip resonators as their quality factor drops below one. We also observe a step-like enhancement of the current roughly above $V = \Delta_{\text{Al}}/e$ in both Al/Nb and all-Al JJs, resulting probably from Andreev tunneling [15].

We model the single JJ I - V characteristics using the $P(E)$ -theory. The electromagnetic environment seen by the JJ is a parallel connection of the junction capacitance C_J and transmission line impedance [12] $2Z_0[Z_L + Z_0 \tanh(\gamma\ell)]/[Z_0 + Z_L \tanh(\gamma\ell)]$, where the factor 2 emerges from the fact that we have effectively two equivalent resonators in series, and $\gamma\ell = R_{\text{Au}}/2Z_0 + i\pi\omega/\omega_0$. In the simulations, we have used the junction capacitance

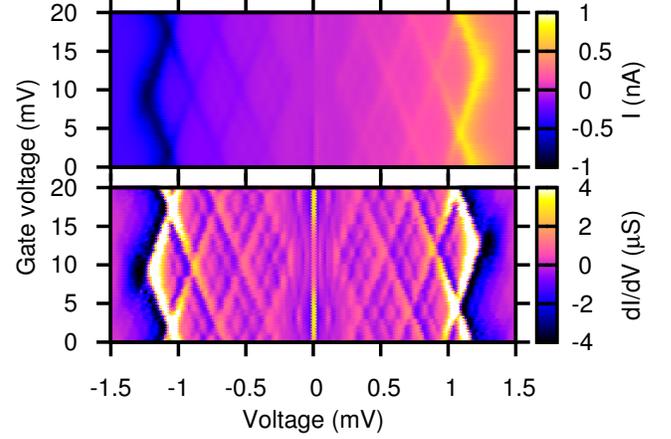


FIG. 2: (Color online) Current (upper panel) and differential conductance dI/dV (lower panel) through the Al-Nb-Al SSET as a function of the gate and bias voltages. The characteristics are e -periodic as a function of the gate and consist of rhombi-shape cells, which are due to the subgap JQP cycles (see the text), ending with intense normal JQP cycles at higher bias voltages. Differential conductance reveals resonant peak structure in each cell.

$C_J = 1 \text{ fF}$ and the fundamental resonance frequency $\omega_0/2\pi = 29.4 \text{ GHz}$ assuming also that the resonances are equidistant. In Fig. 1 we see a reasonably good agreement between the simulated curve and the measured ones for both peak positions and magnitude. The shift of the higher resonant peaks towards the origin visible in the experimental curves can be explained by the fact that for the given leads geometry the resonances occur not at multiples of ω_0 but at lower frequencies. This is confirmed by more detailed microstrip analysis performed with Microwave Office. Multiphoton transitions (to the fundamental mode) could also result in a similar peak structure, but are present with negligible magnitudes.

We then turn to characterization of the SSET transport shown in a large scale in Fig. 2. The Josephson-quasiparticle (JQP) current [16] is seen at about $V = \pm 1.2 \text{ mV}$ but also rhombi-shape cells exist at lower voltages, starting already from 0.18 mV , with the gate modulation period of about 15 mV . The lower voltage structure occurs also due to the JQP processes. Such a multiple JQP peak structure in Al/Nb SSETs has been observed and discussed in earlier works [17–19]. The new feature here is the structure inside the cells, see also Fig. 3a.

Our simulations of the SSETs are based on the density-matrix approach (DMA) developed in Ref [20], with supplements given below. The model describes charge transport via incoherent Cooper-pair tunneling taking place at voltages above the supercurrent branch. To account for the subgap density of states (DOS) in the niobium (island) we use a broadened BCS DOS of the form [21]

$$n(E) = \left| \text{Re} \left\{ \frac{E - i\Gamma}{\sqrt{(E - i\Gamma)^2 - \Delta_{\text{Nb}}^2}} \right\} \right|, \quad (1)$$

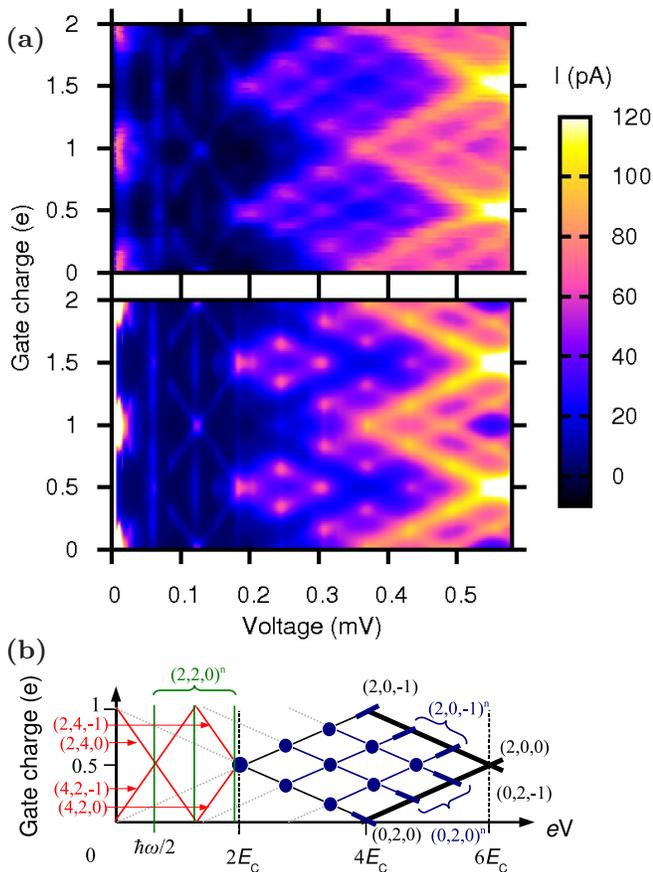


FIG. 3: (Color online) (a): Measured current (upper panel) shown in Fig. 2 but in a smaller scale, and the current calculated by the DMA (lower panel). Since the DMA does not hold in the supercurrent region the numerical results are shown from 10 μV . The parameters in the simulation are $\Delta_{\text{Al}} = 215 \mu\text{eV}$, $\Delta_{\text{Nb}} = 1.15 \text{ meV}$, $\Gamma = \Delta_{\text{Nb}}/80$, $r = 1/45 \mu\text{s}$, $T = 100 \text{ mK}$. The EE seen by the SSET is characterized in the text. (b): Origin of the resonance structure. In a resonant tunneling $(a, b, i)^n$ the charge ae (be) tunnels across the left (right) JJ with the simultaneous excitation of the n -th mode, the island charge being initially ie [20]. At low voltages only the third-order CP tunneling resonances are seen [$(a+b)/2 = 3$], in addition to cotunneling ($a=b$) with the simultaneous excitation of a corresponding mode. At higher voltages the subgap JQP cycles, enabled by niobium's subgap DOS, become first possible at double resonance points (dots) and eventually nearby thick solid lines.

where Γ is a broadening parameter. At low energies such a DOS is a constant, $\Gamma/\Delta_{\text{Nb}}$, resembling the metallic DOS. Further, we assume that an unpaired electron tunneled into the niobium island relaxes quickly to the Fermi level due to the significant subgap DOS. This kills the asymmetry of the tunneling rates for different parities of the island [22] and results in e -periodic characteristics.

We also see the effects due to non-equilibrium quasiparticles [23] entering the island from the leads at energy Δ_{Al} or higher. For qualitative modeling we assume that the electron tunneling rates into and out of the island are

equal and described by the expression [24]

$$R(E) = \frac{r}{1 + \exp[-(E + \Delta_{\text{Al}} - \Delta_i)/k_B T]}, \quad (2)$$

where Δ_i is the energy gap in the island, E the energy change in the SSET and the maximum rate r characterizes the magnitude of the leakage. In the ideal case practically none of the quasiparticles get through due to large $\Delta_i = \Delta_{\text{Nb}}$, however, due to significant subgap DOS we put $\Delta_i = 0$ and calculate the non-equilibrium part of the quasiparticle tunneling using $R(E)$ as a prefactor of the corresponding Lindblad operators [20].

Numerical results obtained by the DMA are compared with the experiment in Fig. 3. The Josephson coupling energies are deduced from the transport measurements giving $R_1 + R_2 = 73 \text{ k}\Omega$ and assuming that $R_1 = R_2$. The charging energy of the island is obtained from the cell structure giving $E_C \approx 93 \mu\text{eV}$ ($C_1 \approx C_2$). As the effective EE seen by the SSET we use practically the same impedance that fitted the single JJ data but using $C_J = C_1/2$. In the DMA, the environmental impedance is included directly in the tunneling rate, similarly as in [8]. This approximation neglects the rare multiphoton transitions. In order to model (non-Markovian) low-frequency background charge fluctuations, we have also averaged the numerical results with respect to the gate charge with a Gaussian distribution of width $4e/100$.

Let us analyze first the novel features observed in this work. Due to the broadened DOS in the niobium the onset of the (subgap) JQP cycle occurs when enough energy can be released to create an excitation on the aluminum side of the JJs. This leads to the threshold $eV = \Delta_{\text{Al}} - E_C$ for the double JQP cycle and $eV = \Delta_{\text{Al}} + E_C$ for the ordinary (but subgap) JQP cycle. The resonances appear first at double JQP points (in Fig. 3 at the low voltage corners of the JQP cells, i.e., at $eV = 2E_C \approx 185 \mu\text{eV}$ and $Q_0 = e/2 + me$) and approximately above the threshold $eV = \Delta_{\text{Al}} + E_C$ as continuous resonance lines. Inside each of the JQP cells there is a fine structure due to the coupling to the resonant modes of the transmission lines. The origin is that the Cooper-pair tunneling in the JQP process can also be resonant if the extra energy released is absorbed by the environmental mode. This leads to extra JQP- n lines located at $n\hbar\omega_0/e$ above the main resonant voltages, each corresponding to a photon emission to the n th mode. These extra resonances show similar behavior as the main JQP resonances and appear first as dots at double resonance points, and as resonance lines at higher bias voltages. The exact thresholds are $eV = \Delta_{\text{Al}} \pm E_C + n\hbar\omega_0/2$ corresponding to double resonances ($-$ sign) and resonance lines ($+$ sign). For the double resonance to occur, two simultaneous resonances corresponding to two different parities of the island charge must coexist, and the resonant states must match. It follows from this that the double JQP- n resonances can occur only inside the triangle-shaped areas starting at $eV = 2E_C$. The subgap JQP structure disappears finally after the onset of the ordi-

nary JQP cycle at $eV \approx \Delta_{\text{Al}} + \Delta_{\text{Nb}}$ (see Fig. 2). The position of this ordinary JQP is reduced from the ideal one $\Delta_{\text{Al}} + \Delta_{\text{Nb}} + E_C < eV < \Delta_{\text{Al}} + \Delta_{\text{Nb}} + 3E_C$ due to the high subgap leakage of Nb based junctions, which is described by the broadened DOS, and due to quantum Zeno effect in the charge transport [20], as nearby the threshold the quasiparticle rate is high compared to the Josephson coupling energies.

The region of the intermediate voltages (50–200 μV) reveals resonances due to the Cooper-pair cotunneling across both JJs and a simultaneous photon emission to the first mode, which enhances the current at $V \approx 61 \mu\text{V}$. While the position of the resonance is gate independent, its magnitude increases when also first- or third-order Cooper-pair tunneling (without photon emission) becomes resonant, see also Fig. 3b. Also traces of further modes via such cotunneling can be found at multiples of this voltage. The third-order Cooper-pair tunneling resonances [20], corresponding to $4e$ tunneling across one and $2e$ tunneling across the other JJ, are seen as sloping resonance lines in the range 80 – 180 μV . These resonances were reported also in earlier works [25, 26].

Finally, we come to the supercurrent region (0–50 μV). The current peaks are e -periodic, resulting from the presence of significant subgap DOS. The number of electrons on the island is described by an integer m . As there is no extra energy related to an odd m , the system tends to minimize the electrostatic energy $(me - Q_0)^2/2C$ through slow higher-order processes. It therefore avoids

the degeneracy points $|Q_0 - me| = e$, which enable large supercurrents across the system. As a result, in the absence of external quasiparticle leakage, there should be no significant supercurrent, and it has maxima at $Q_0 = e/2 + me$ (with integer m). This is not the case in the experiment. Indeed, the smallness of the subgap normal-superconductor tunneling current makes it possible that a small leakage current ($1/r$ between micro- and millisecond) opposes the slow higher-order processes and provides strong supercurrent peaks at $Q_0 = e + me$.

In summary, we have observed pronounced current peaks in the SET transport resulting from the Cooper pair tunneling and simultaneous single photon emission into the resonant modes. They are seen in a wide range of bias voltages due to the finite electronic subgap DOS in the niobium island. These gate dependent peaks have the same origin as those observed at a lower bias voltage that do not depend on the gate voltage. Also, all these peaks have their analogs in transport through single Josephson junctions, which were reported earlier. Apparently, the observed resonances may be detrimental to various practical devices as they, e.g., cause extra decoherence of quantum bits and errors in charge pumps.

We thank S. Ashhab, D. V. Averin, A. Maassen van den Brink, M. Marthaler, G. Schön, and A. Zagoskin for fruitful discussions. This work was supported by the JSPS through its FIRST Program, JST-CREST and MEXT kakenhi “Quantum Cybernetics”.

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